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## **Listing of Claims**

- 1. (Cancelled)
- 2. (Cancelled)
- 3. (Cancelled)
- 4. (Cancelled)
- 5. (Cancelled)
- 6. (Cancelled)
- 7. (Cancelled)
- 8. (Cancelled)
- 9. (Cancelled)
- 10. (Cancelled)
- 11. (Cancelled)
- 12. (Cancelled)
- 13. (Cancelled)
- 14. (Cancelled)
- 15. (Currently Amended) A liquid composition for depositing an active material selected from electrically active materials, photoactive materials, and mixtures of such materials, onto a surface, said composition comprising:

thean active material selected from semiconductive materials, photoactive materials and mixtures of such materials; and at least one liquid medium selected from compounds having the structure

$$(R)_m$$
  $(X)_n$ 

wherein:

R is  $C_1$ - $C_{10}$  alkyl,  $C_1$ - $C_{10}$  alkoxy, or  $C_1$ - $C_{10}$  oxyalkyl,

R<sub>f</sub> is C<sub>2</sub>-C<sub>3</sub> fluorinated alkyl, C<sub>1</sub>-C<sub>10</sub> fluorinated alkenyl, C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkyl, or C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkenyl,

X is H, F, Cl, Br, C<sub>1</sub>-C<sub>10</sub> alkyl, C<sub>1</sub>-C<sub>10</sub> alkoxy C<sub>1</sub>-C<sub>10</sub> oxyalkyl, C<sub>1</sub>-C<sub>10</sub> fluorinated alkyl, C<sub>1</sub>-C<sub>10</sub> fluorinated alkenyl, C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkyl, or C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkenyl,

m is from 0-5, and

n is from 0-5, wherein m + n is no greater than 5.

- 16. (Cancelled)
- 17. (Cancelled)
- 18. (Cancelled)
- 19. (Cancelled)
- 20. (Cancelled)
- 21. (Cancelled)
- 22. (Currently Amended) A liquid composition for depositing an active material selected from electrically active materials, photoactive materials, and mixtures of such materials, onto a surface, said composition comprising:

thean active material selected from electrically active materials, photoactive materials and mixtures of such materials; and

at least one liquid medium selected from compounds A through O and mixtures thereof:

23. (Currently Amended) A liquid composition for depositing an active material selected from electrically active materials, photoactive materials, and mixtures of such materials, onto a surface, said composition comprising:

thean active material selected from electrically active materials, photoactive materials and mixtures of such materials; and

at least one liquid medium selected from compounds having the structure

$$(R)_m$$
  $(X)_m$ 

wherein:

R and X are each, independently, C<sub>1</sub>-C<sub>10</sub> alkyl, C<sub>1</sub>-C<sub>10</sub> alkoxy, or C<sub>1</sub>-C<sub>10</sub> oxyalkyl, R<sub>f</sub> is C<sub>2</sub>-C<sub>3</sub> fluorinated alkyl, C<sub>1</sub>-C<sub>10</sub> fluorinated alkenyl, C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkyl, or C<sub>1</sub>-C<sub>10</sub> fluorinated oxyalkenyl,

m is from 0-5, and

n is from 0-5, wherein m + n is no greater than 5.

- 24. (Previously Presented) A liquid composition of claim 15 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 25. (Previously Presented) A liquid composition of claim 15 wherein the static contact angle is no more than 35 degrees.
- 26. (Previously Presented) A liquid composition of claim 15 wherein the static contact angle is no more than 20 degrees.
- 27. (Previously Presented) A liquid composition of claim 22 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 28. (Previously Presented) A liquid composition of claim 22 wherein the static contact angle is no more than 35 degrees.
- 29. (Previously Presented) A liquid composition of claim 22 wherein the static contact angle is no more than 20 degrees.
- 30. (Previously Presented) A liquid composition of claim 23 capable of forming a static contact angle of no greater than 40 degrees on said surface.
- 31. (Previously Presented) A liquid composition of claim 23 wherein the static contact angle is no more than 35 degrees.

32. (Previously Presented) A liquid composition of claim 23 wherein the static contact angle is no more than 20 degrees.